

L Number	Hits	Search Text	DB	Time stamp
1	118329	((unercoat\$3) or (silicon near3 nitride) or (SiN Si3N4) ("Si.sub.3" adj "N.sub.4") or (silicon near3 oxynitride) or (oxynitride SiON)	USPAT; US-PGPUB	2003/03/16 12:32
2	31594	((unercoat\$3) or (silicon near3 nitride) or (SiN Si3N4) ("Si.sub.3" adj "N.sub.4") or (silicon near3 oxynitride) or (oxynitride SiON)) and (organic PR photo?resist PR)	USPAT; US-PGPUB	2003/03/16 12:33
3	1213	((unercoat\$3) or (silicon near3 nitride) or (SiN Si3N4) ("Si.sub.3" adj "N.sub.4") or (silicon near3 oxynitride) or (oxynitride SiON)) and (organic PR photo?resist PR)) and (wet near10 (clean\$4 treat\$6))	USPAT; US-PGPUB	2003/03/16 12:33
4	2	((unercoat\$3) or (silicon near3 nitride) or (SiN Si3N4) ("Si.sub.3" adj "N.sub.4") or (silicon near3 oxynitride) or (oxynitride SiON)) and (organic PR photo?resist PR)) and (wet near10 (clean\$4 treat\$6))) and (far near5 (infra?red IR))	USPAT; US-PGPUB	2003/03/16 12:33
6	54	((unercoat\$3) or (silicon near3 nitride) or (SiN Si3N4) ("Si.sub.3" adj "N.sub.4") or (silicon near3 oxynitride) or (oxynitride SiON)) and (organic PR photo?resist PR)) and (wet near10 (clean\$4 treat\$6))) and ((propylene near3 glycol near3 mono?methyl near3 ether) (ethyl near3 lactate) (methyl near3 methoxy near3 propionate) 2?heptanone (ethyl near3 pyruvate) (methyl near3 cellosolve near3 acetate) (ethyl near3 methoxy near3 propionate) (propylene near3 glycol near3 mono?ethyl near3 ether near3 acetate) (ethyl near3 methoxy near3 propionate) (methyl near3 lactate) (methyl near3 pyruvate))	USPAT; US-PGPUB	2003/03/16 12:34
7	58405	((unercoat\$3) or (silicon near3 nitride) or (SiN Si3N4) ("Si.sub.3" adj "N.sub.4") or (silicon near3 oxynitride) or (oxynitride SiON)	EPO; JPO; DERWENT; IBM_TDB	2003/03/16 12:32
8	2547	((unercoat\$3) or (silicon near3 nitride) or (SiN Si3N4) ("Si.sub.3" adj "N.sub.4") or (silicon near3 oxynitride) or (oxynitride SiON)) and (organic PR photo?resist PR)	EPO; JPO; DERWENT; IBM_TDB	2003/03/16 12:33
9	8	((unercoat\$3) or (silicon near3 nitride) or (SiN Si3N4) ("Si.sub.3" adj "N.sub.4") or (silicon near3 oxynitride) or (oxynitride SiON)) and (organic PR photo?resist PR)) and (wet near10 (clean\$4 treat\$6))	EPO; JPO; DERWENT; IBM_TDB	2003/03/16 12:33
12	0	((unercoat\$3) or (silicon near3 nitride) or (SiN Si3N4) ("Si.sub.3" adj "N.sub.4") or (silicon near3 oxynitride) or (oxynitride SiON)) and (organic PR photo?resist PR)) and ((propylene near3 glycol near3 mono?methyl near3 ether) (ethyl near3 lactate) (methyl near3 methoxy near3 propionate) 2?heptanone (ethyl near3 pyruvate) (methyl near3 cellosolve near3 acetate) (ethyl near3 methoxy near3 propionate) (propylene near3 glycol near3 mono?ethyl near3 ether near3 acetate) (ethyl near3 methoxy near3 propionate) (methyl near3 lactate) (methyl near3 pyruvate))	EPO; JPO; DERWENT; IBM_TDB	2003/03/16 12:34

11	0	((((unercoat\$3) or (silicon near3 nitride) or (SiN Si3N4) ("Si.sub.3" adj "N.sub.4") or (silicon near3 oxynitride) or (oxynitride SiON)) and (organic PR photo?resist PR)) and (wet near10 (clean\$4 treat\$6))) and (far near5 (infra?red IR)))	EPO; JPO; DERWENT; IBM_TDB	2003/03/16 12:34
13	1	((((unercoat\$3) or (silicon near3 nitride) or (SiN Si3N4) ("Si.sub.3" adj "N.sub.4") or (silicon near3 oxynitride) or (oxynitride SiON)) and (organic PR photo?resist PR)) and (far near5 (infra?red IR)))	EPO; JPO; DERWENT; IBM_TDB	2003/03/16 12:35